ECSEL dynamic and success stories

Soitec vision

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Introduction

- EC Political guidelines (Ursula von der Leyen)
 - (1) A European Green Deal: "World leader in circular economy and clean technologies"
 - (3) A Europe fit for the digital age: "technological sovereignty in some critical technology areas"
- Low consumption semiconductors are urgently required to address the Green challenge
 - Energy and material consumption reduction is in our innovation DNA
- European autonomy on key technologies requires the establishment of a complete value chain starting from the material
 - Soitec engineered substrates: a solid foundation to achieve industrial autonomy





Soitec – Designer & Manufacturer of Innovative Semiconductor Material

We design and deliver innovative substrates & solutions to enable our customers' products shaping everyday life

Largest manufacturer of engineered substrates

2

Unique technologies
SMART CUT™, SMART STACKING

High-growth markets
SMARTPHONES, AUTOMOTIVE, CLOUD & INFRASTRUCTURE, IOT

6

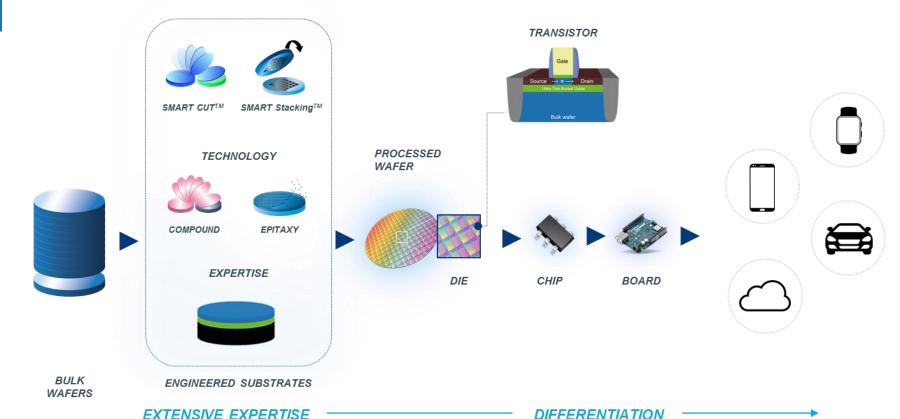
Wafer fabs (150, 200 & 300 mm)
FRANCE, BELGIUM, SINGAPORE, CHINA*

1,450

Employees Worldwide GLOBAL PRESENCE

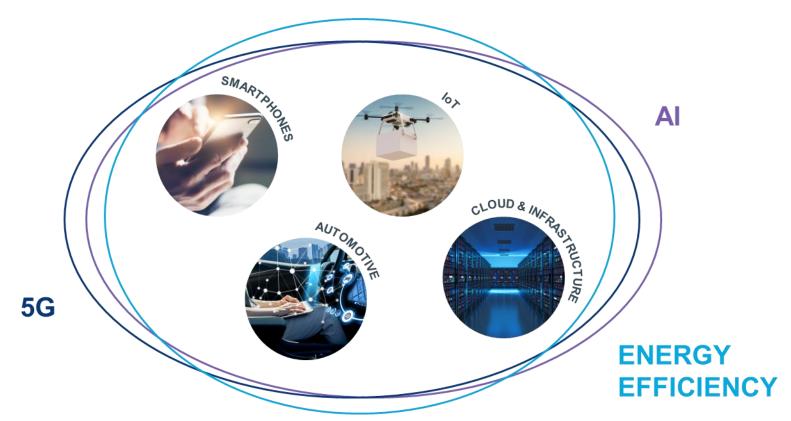


Substrates in the value chain



seitec

Serving 4 key markets & 3 Mega trends





Broad product portfolio addressing market growth

PROCESSOR & CONNECTIVITY SOC

RF **FRONT-END MODULE**

POWER

PHOTONICS

IMAGERS

PIEZO-ON-**INSULATOR**

POI

For high

performance 5G

filters

GaN

FD-SOI

For power-efficient integration of digital/ ²analog/RF



RF-SOI

For highly efficient mobile communication

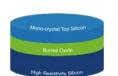


Power-SiC Photonics-SOI For high voltage For high voltage For high perf. photonics device integration device integration device integration into

Handle substrates

NEW

silicon



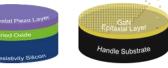
Imager-SOI For improved imager

performance in NIR



GaN

For radio frequency (RF) 5G and power systems



18/02/2020









Base Silicon











What ECSEL is about:

- > Strategy:
 - Align European Challenges and industrial strategies to maximize impact
- **>** Ambition:
 - Ambitious funding to share risks, to accelerate R&D
- Ecosystem:
 - To improve visibility: « Soitec inside »
 - To improve European Market penetration



Strategy: ECSEL supports our strategic products



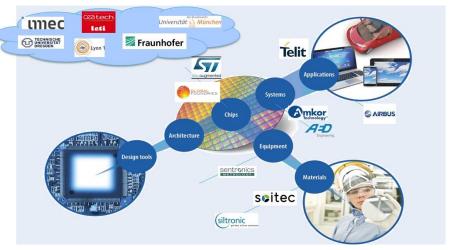




REFERENCE success story (2016-2019)



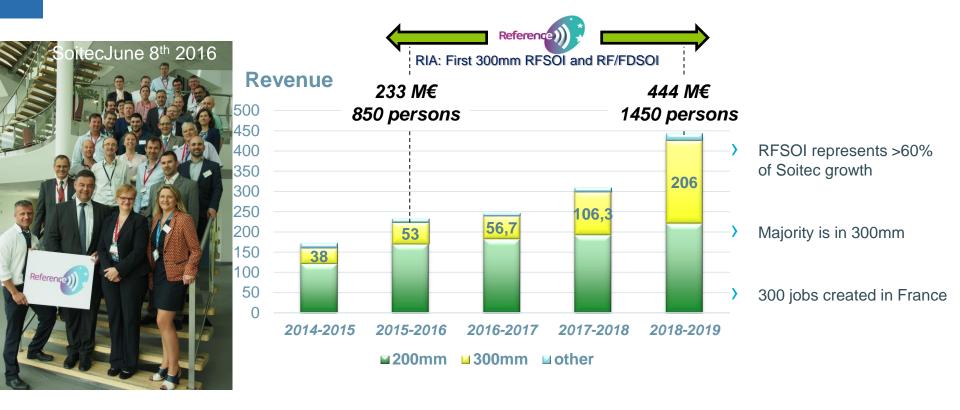




- Develop innovative 300mm RF-SOI substrates & technologies
- Enabling realization of integrated Front End modules, and system level demonstrators for cellular, Aeronautics, automotive, and...
- ... Paving the way to 5G



REFERENCE Impact: 300mm RF-SOI in production and essential for 5G





BEYOND5: 2020 – 2023 SOI penetration in Edge AI and 5G







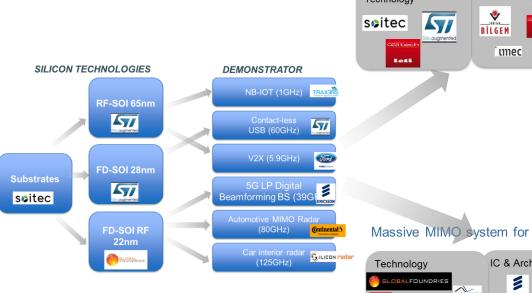
BEYOND 5 – a follow-up of REFERENCE - aims to demonstrate European technological sovereignty for:

- 5G infrastructure / IoT
- Automotive communications
- Smart sensors including Edge Al



BEYOND5: 2020 - 2023 Turkish partners demonstrators

Ford Otosan – V2X Communication @ Autonomous Construction Site













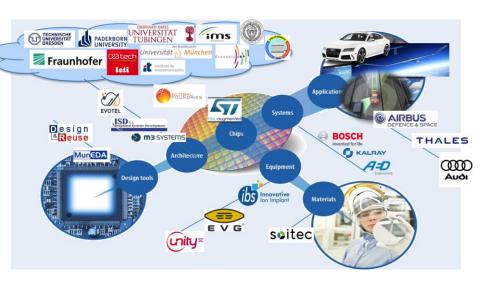




OCEAN12: 2018-2021 Low power high perf computing







- OCEAN12 fosters the FDSOI Market penetration for Ultra low power highly performant computing
- Bosch announced major investments to develop automotive radars on 22FDX







Coming challenges on material: Example of SiC







- > Soitec target: create a new SiC substrate standard based on Smart Cut technology
- Ambition from the application perspectives
 - Provide technology solutions for a climate neutral eMobility
 - Foster a trusted and secure European supply chain for SiC solutions





TAKE AWAYS

- Innovation in nano-electronics starts at substrate and material level
- Soitec ecosystem brings green technologies and solutions for European autonomy
 - Low consumption Edge AI and FDSOI technology
 - Climate Neutral e-mobility and SiC technology
- ECSEL JU is critical to structure the European collaborative ecosystem





ECSEL SOI Ekosistemimize hoş geldiniz

TEŞEKKÜR EDERİM

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